	Application No.	Applicant(s)	(Un)
	10/733,384	SUZUKI, HIRONOBU	('
Notice of Allowability	Examiner	Art Unit	
	Tony Ko	2878	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.			
1. This communication is responsive to 7/12/05.			
2. The allowed claim(s) is/are <u>1-7</u> .			
 3. Acknowledgment is made of a claim for foreign priority unal (a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 			
2. Certified copies of the priority documents have been received in Application No			
3. Copies of the certified copies of the priority documents have been received in this national stage application from the			
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.			
4. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.			
5. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.			
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached			
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).			
6. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.			
Attachment(s) 1. Notice of References Cited (PTO-892)	5. Notice of Informal F	Patent Application (PTO-15	52)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary Paper No /Mail Da		
3. Information Disclosure Statements (PTO-1449 or PTO/SB/C Paper No./Mail Date	Paper No./Mail Da 08), 7. ☐ Examiner's Amendr	ment/Comment	
4. Examiner's Comment Regarding Requirement for Deposit	8. Examiner's Statement	ent of Reasons for Allowar	ıce
of Biological Material	9.		

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EXAMINER'S AMENDMENT

EXAMINER'S AMENDMENT

- 1. Applicant's election of claims 1-7 in the reply filed on 7/12/05 is acknowledged. Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)).
- 2. This application is in condition for allowance except for the presence of claims 8 to 15 non-elected without traverse. Accordingly, claims 8 15 have been cancelled.

DETAILED ACTION

Allowable Subject Matter

- Claims 1-7 are allowed.
- 2. The following is an examiner's statement of reasons for allowance: Prior art discloses a photoelectric conversion section formed on the surface of a semiconductor substrate; and a charge transfer section having a charge transfer electrode for transferring electric charges produced by the photoelectric conversion section, wherein the charge transfer electrode of the charge transfer section comprises a first electrode layer comprising a silicon conductive film formed on a gate oxide film formed on the surface of the semiconductor substrate; a second electrode layer comprising a silicon conductive film formed on a gate oxide film wherein the second electrode layer is formed to sit astride and run on said first electrode layer; a sidewall dielectric film

formed on sidewalls of said first and second electrode layers. Prior art does not disclose the first and second electrode layers share a common end and each of the first and second electrode have a non-common end, wherein, at the non-common ends of the first and second electrodes, the sidewall dielectric film is formed solely on the sidewalls.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tony Ko whose telephone number is 571-272-1926.

The examiner can normally be reached on Monday-Friday 7:30 - 4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Dave Porta can be reached on 571-272-2444. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TKO

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